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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO
10/662,474	09/16/2003	Hiroyuki Hyodo	031161	9634
38834	7590 12/15/2004		EXAM	INER
WESTERMAN, HATTORI, DANIELS & ADRIAN, LLP			COLEMAN, WILLIAM D	
SUITE 700	CTICUT AVENUE, NV	V	ART UNIT	PAPER NUMBER
WASHINGTON, DC 20036		2823		

DATE MAILED: 12/15/2004

Please find below and/or attached an Office communication concerning this application or proceeding.

	Application No.	Applicant(s)			
Office Action Summary	10/662,474	HYODO ET AL.			
	Examiner	Art Unit			
The MAILING DATE of this communication as	W. David Coleman	2823			
The MAILING DATE of this communication appears on the cover sheet with the correspondence address Period for Reply					
A SHORTENED STATUTORY PERIOD FOR REP THE MAILING DATE OF THIS COMMUNICATION - Extensions of time may be available under the provisions of 37 CFR 1 after SIX (6) MONTHS from the mailing date of this communication. - If the period for reply specified above is less than thirty (30) days, a re - If NO period for reply is specified above, the maximum statutory period - Failure to reply within the set or extended period for reply will, by statu Any reply received by the Office later than three months after the mail earned patent term adjustment. See 37 CFR 1.704(b).	136(a). In no event, however, may a reply be to ply within the statutory minimum of thirty (30) day within the statutory minimum of thirty (30) day will apply and will expire SIX (6) MONTHS from the cause the application to become ABANDON	imely filed ys will be considered timely, the mailing date of this communication. ED (35 U.S.C. § 133)			
Status					
1) Responsive to communication(s) filed on <u>30 September 2004</u> .					
2a) This action is FINAL . 2b) This action is non-final.					
3) Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11, 453 O.G. 213.					
closed in accordance with the practice under	Ex parte Quayle, 1935 C.D. 11, 4	153 O.G. 213.			
Disposition of Claims					
4)⊠ Claim(s) <u>1-35</u> is/are pending in the application.					
4a) Of the above claim(s) 1-17,32 and 33 is/are withdrawn from consideration.					
5) Claim(s) is/are allowed.					
6) Claim(s) <u>18-31,34 and 35</u> is/are rejected.					
7) Claim(s) is/are objected to.					
8) Claim(s) are subject to restriction and	or election requirement.	·			
Application Papers					
9)☐ The specification is objected to by the Examir	ner.				
10)☐ The drawing(s) filed on is/are: a)☐ accepted or b)☐ objected to by the Examiner.					
Applicant may not request that any objection to th	e drawing(s) be held in abeyance. Se	ee 37 CFR 1.85(a).			
Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d).					
11) The oath or declaration is objected to by the I	Examiner. Note the attached Offic	e Action or form PTO-152.			
Priority under 35 U.S.C. § 119					
12)⊠ Acknowledgment is made of a claim for foreig	in priority under 35 U.S.C. § 1196	a)-(d) or (f).			
a)⊠ All b)□ Some * c)□ None of:	, ,	-, (-, -, (,			
 Certified copies of the priority documents have been received. 					
2. Certified copies of the priority documents have been received in Application No					
3. Copies of the certified copies of the pri	-	ved in this National Stage			
application from the International Bure	, , , ,				
* See the attached detailed Office action for a lis	st of the certified copies not receive	ved.			
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Attachment(c)					
Attachment(s) 1) Notice of References Cited (PTO-892)	4) 🔲 Interview Summa	·v (PTO-413)			
2) Notice of Draftsperson's Patent Drawing Review (PTO-948)	Paper No(s)/Mail I	Date			
3) Information Disclosure Statement(s) (PTO-1449 or PTO/SB/06) Paper No(s)/Mail Date 9/03.	5) Notice of Informal 6) Other:	Patent Application (PTO-152)			
U.S. Patent and Trademark Office					
PTOL-326 (Rev. 1-04) Office	Action Summary F	Part of Paper No./Mail Date 12102004			



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DETAILED ACTION

Election/Restrictions

1. Applicant's election without traverse of Group II, claims 18-31, 34 and 35 in the reply filed on September 30, 2004 is acknowledged.

Claim Rejections - 35 USC § 102

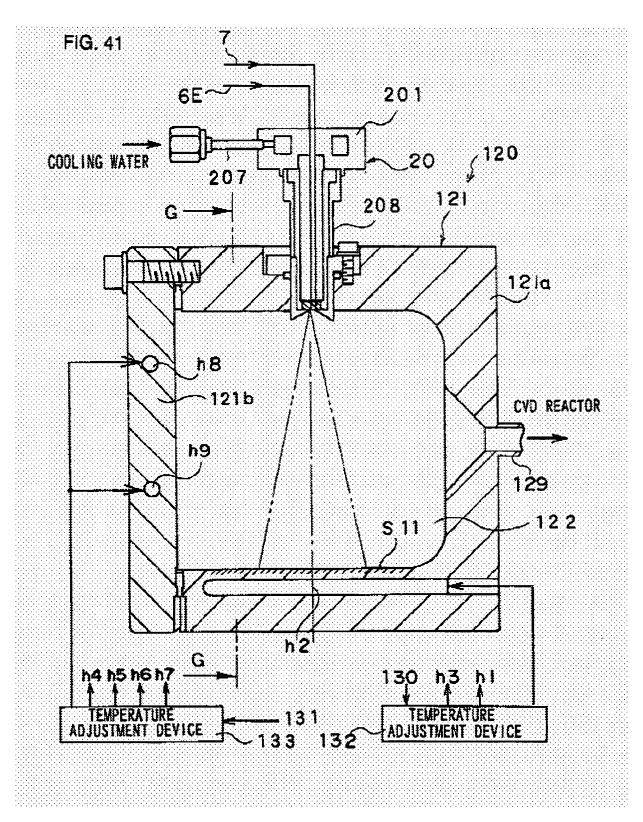
2. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

- (e) the invention was described in (1) an application for patent, published under section 122(b), by another filed in the United States before the invention by the applicant for patent or (2) a patent granted on an application for patent by another filed in the United States before the invention by the applicant for patent, except that an international application filed under the treaty defined in section 351(a) shall have the effects for purposes of this subsection of an application filed in the United States only if the international application designated the United States and was published under Article 21(2) of such treaty in the English language.
- 3. Claims 18-31, 34 and 35 are rejected under 35 U.S.C. 102(e) as being anticipated by Yoshioka et al., U.S. Patent Application Publication No: 2002/0043215 A1.
- 4. <u>Yoshioka</u> discloses a semiconductor apparatus as claimed. Please see **FIGS. 1-49**, where <u>Yoshioka</u> teaches the claimed invention.



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5. Pertaining to claim 18, <u>Yoshioka</u> teaches an apparatus for gasifying a solid material comprising:

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a solvent removal chamber 120 provided with an inlet port 6E/7 of a gasification solvent containing a first solid material (Ba, Sr and Ti), [paragraph 0079] and a solvent (THF, tetrahydrofuran) in which it is dissolved, a heating device131 that vaporizes the solvent used to prepare the gasification solution by heating that solution, and an exhaust port 129 that removes the vaporization product of the solvent, and a solid sublimation chamber (i.e., CVD Reactor) either also used as the solvent removal chamber or arranged communicably adjacent to it, and provided with a heating device that gasifies a second solid material separated by removal of the solvent by sublimation.

- 6. Pertaining to claim 19, <u>Yoshioka</u> teaches an apparatus for gasifying a solid material as set forth in claim 18, wherein the solvent removal chamber and the following solid sublimation chamber are arranged to be separated by an opening and closing partition **V6** (as seen in FIG. 20)
- 7. Pertaining to claim 20, <u>Yoshioka</u> teaches an apparatus for gasifying a solid material as set forth in claim 18, wherein the combination solvent removal/solid sublimation chamber is provided with a heating device 65/66 capable of adjusting the heating temperature to vaporize the solvent used prepare the gasification solution by heating it, and gasify the second solid material by sublimation.
- 8. Pertaining to claim 21, <u>Yoshioka</u> teaches an apparatus for gasifying a solid material as set forth in claim 18, wherein the solvent removal chamber and the solid sublimation chamber, or

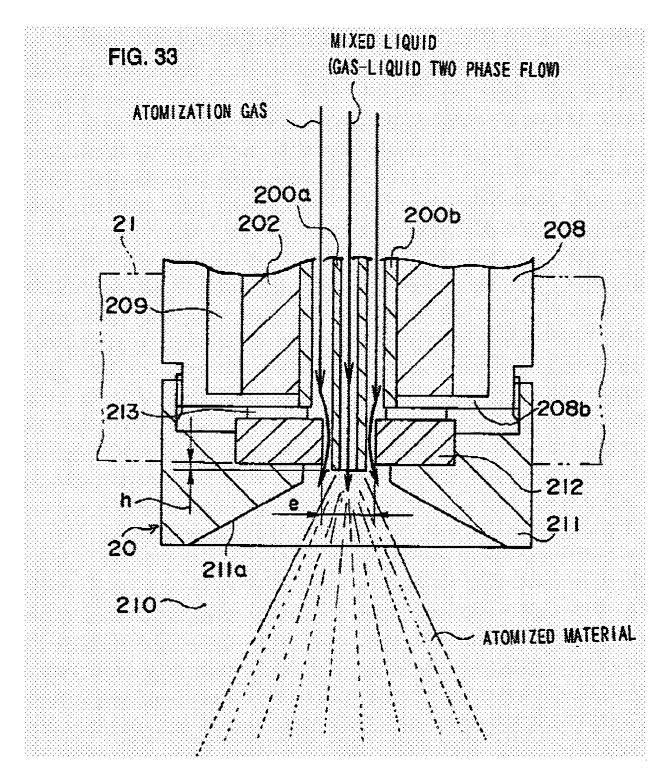
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the combination solvent removal/solid sublimation chamber 13 (drain tank as seen in FIG. 22), are respectively composed of closed spaces.

9. Pertaining to claim 22, <u>Yoshioka</u> teaches an apparatus for gasifying a solid material as set forth in claim 18, wherein the solvent removal chamber or combination solvent removal/solid sublimation chamber is provided with a dissemination means 210 (see FIG. 33 below) that introduces the gasification solution in the form of fine droplets.

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10. Pertaining to claim 23, <u>Yoshioka</u> teaches an apparatus for gasifying a solid material as set forth in claim 18, wherein the solvent removal chamber or the combination solvent removal/solid

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sublimation chamber additionally has a carried solid to which the second solid material is adhered in the form of fine solid particles (the Examiner takes the position that either the substrate or the vacuum pump meets this limitation).

- 11. Pertaining to claim 24, <u>Yoshioka</u> teaches an apparatus for gasifying a solid material as set forth in claim 23, wherein the solid carrier is a porous material (bismuth, paragraph 0180) arranged in the solvent removal chamber.
- 12. Pertaining to claim 25, <u>Yoshioka</u> teaches an apparatus for gasifying a solid material as set forth in claim 24 additionally having a transport means that moves the porous material from the solvent removal chamber to the solid sublimation chamber.
- 13. Pertaining to claim 26, <u>Yoshioka</u> teaches an apparatus for gasifying a solid material as set forth in claim 23, wherein the solid carrier is a porous inner wall of the combination solvent removal/solid sublimation chamber (the Examiner takes the position that porous materials have inter-walls).
- 14. Pertaining to claim 27, <u>Yoshioka</u> teaches an apparatus for gasifying a solid material as set forth in claim 23, wherein the solid carrier is composed of a porous metal material.

Pertaining to claim 28, <u>Yoshioka</u> teaches an apparatus for gasifying a solid material as set forth in claim 23, wherein the solid carrier is composed of a porous ceramic material PZT and TiO₂ are ceramic materials, paragraph 0180).

15. Pertaining to claim 29, <u>Yoshioka</u> teaches an apparatus for gasifying a solid material as set forth in claim 18, wherein the solid sublimation chamber or combination solvent removal/solid sublimation chamber is additionally provided with a carrier gas inlet for transferring reactive gas

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generated by sublimation of the second solid material to a following treatment chamber (see FIG. 2 where a carrier gas is disclosed).

- 16. Pertaining to claim 30, <u>Yoshioka</u> teaches an apparatus for gasifying a solid material as set forth in claim 18, wherein the first solid material is composed of at least one type of organometallic compound (please note that THF is part of the organometallic compound).
- 17. Pertaining to claim 31, <u>Yoshioka</u> teaches an apparatus for gasifying a solid material as set forth in claim 30, wherein the organometallic compound is selected from the group consisting of Pb(DPM)z, Zr(DPM)Q, Ti(i.PrO)2(DPM)2, Ba(DPM)2, Sr(DPM)2, Ta (O-Et), and Bi (DPM) 3

Pertaining to claim 34, <u>Yoshioka</u> teaches an apparatus for forming a thin film from a solid material comprising:

a solvent removal chamber provided with an inlet port of a gasification solvent containing a first solid material and a solvent in which it is dissolved,

a heating device that vaporizes the solvent used to prepare the gasification solution by heating that solution, and an exhaust port that removes the vaporization product of the solvent,

a solid sublimation chamber either also used as the solvent removal chamber or arranged communicably adjacent to it, and

provided with a heating device that gasifies a second solid material separated by removal of the solvent by sublimation, and a film formation chamber wherein the thin film is deposited on a treated substrate using as raw material the reactive gas generated from the second solid material in the solid sublimation chamber or combination solvent removal/solid sublimation chamber (see the rejection of claim 18).

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18. Pertaining to claim 35, <u>Yoshioka</u> teaches an apparatus for forming a. thin film from a solid material as set forth in claim 34 provided with a gasification apparatus as set forth in any one of claims 19 to 31.

Objection

19. Claim 35 is objected to because it depends on multiple dependent claims. Correction is required.

Conclusion

- 20. Any inquiry concerning this communication or earlier communications from the examiner should be directed to W. David Coleman whose telephone number is 571-272-1856. The examiner can normally be reached on 9:00 AM-5:00 PM.
- 21. If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Olik Chaudhuri can be reached on 571-272-1855. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.
- 22. Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

W. David Coleman Primary Examiner Art Unit 2823

WDC